GUS-0344 COPY / OF 2

9 July 1959

STATINTL

Dear

Research Laboratories Eastman Kodak Company Rochester 4, New York

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I have made reservations for and myself on Mohawk flight 923 arriving in Rochester 9:30 a.m.-EDT, Tuesday 21 July and on Mohawk 924 departing from Rochester 5:30 p.m.

Buring our visit we would appreciate the opportunity to discuss, with you and other personnel of the laboratories, the following points:

- 1. Development The possibility of gainfully employing interrupted development on the slower serial emulsions; and also the basis on which development in D-19 for 8 minutes is presently recommended.
- 2. Exposure Indices The method by which the exposure indices, as reported in calculated.
- 3. Resolving Power and Sine Wave Response The conditions under which maximum resolving powers and sine wave response are determined; and for what STATINTL development were the values reported in attachments to letter determined?
- 4. Granularity For the data reported with slit size was used, what was the numerical aperture of the measuring instrument, and on what development were these curves based? Also, in general, technical aspects

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of granularity, particularly as applied to signal-to-noise analysis.

5. Film Handling - From the point of view of static and kinking, what are permissible film transport methods for the emulsions and bases presently being considered.

If you feel that attempting to discuss all these points in the period of time available is too ambitious, please let me know so that we may make arrangements for a longer visit.

Very truly yours

STATINTL

STATINTL

MDR:mb STATINTL

CC: R.M. R.V.

√L.E.W. - Attachment - Letter from